

References

1. K.S. Lee, S.T. Myung, H.J. Bang, S. Chung, and Y.K. Sun, *Electrochim. Acta*, **52**, 5201 (2007).
2. M.S. Whittingham, *Chem. Rev.*, **104**, 4271 (2004).
3. R.J. Gummow, A. de Kock, and M.M. Thackeray, *Solid State Ionics*, **69**, 59 (1994).
4. D.H. Jang, Y.J. Shin, and S.M. Oh, *J. Electrochem. Soc.*, **143**, 2204 (1996).
5. M.M. Thackeray, Y Shao-Horn, and A.J. Kahaian, *Electrochem. Soc. Interface*, **1**, 7 (1998).
6. P. Arora, B.N. Popov, R.E. White, *J. Electrochem. Soc.*, **145**, 1998, 807.
7. J.M. Tarascon, W.R. Mckinnon, F. Coowar, T.N. Bowmer, G. Amatucci, and D. Goynard, *J. Electrochem. Soc.*, **141**, 1421(1994).
8. S.-T Myung, H.-T Chung, S. Komaba, N. Kumagai, and H.-B. Gu, *J. Power Sources*, **90**, 103 (2000).
9. I.H. Kwon and M.Y. Song, *Solid State Ionics*, **158**, 103 (2003).
10. I. Taniguchi, D. Song, and M. Wakihara, *J. Power Sources*, **109**, 333 (2002).
11. Y.-C. Su, Q.-F. Zou, Y.-W. Wang, P. Yu, and J.-Y. Liu, *Mater. Chem. Phys.*, **84**, 302 (2004).
12. B.-H. Kim, Y.-K. Choi, and Y.-H. Choa, *Solid State Ionics*, **158**, 281(2003).
13. C. Julien, S. Ziolkiewicz, M. Lemal, and M. Massot, *J. Mater. Chem.*, **11**, 1837 (2001).
14. B. Deng, H. Nakamura, Q. Zhang, M. Yoshio, and Y. Xia, *Electrochim. Acta*, **49**, 1823 (2004).
15. L.W. Shacklette, T.R. Jow, M. Maxfield, and R. Hatami, *Synth. Metals*, **28**, C655 (1989).
16. M.G. Kanatzidis, *Chem. Eng. News*, **68**, 36 (1990).
17. H. Wang, H. S. Casalongue, Y. Liang, and H. Dai, *J. Am. Chem.Soc.*, **132**, 7472 (2010).
18. H. Wang, L. Cui, Y. Yang, H. S. Casalongue, J. T. Robinson, Y. Liang, Y. Cui, and H. Dai, *J. Am. Chem. Soc.*, **132**, 13978 (2010).
19. S. Yang, G. Cui, S. Pang, Q. Cao, U. Kolb, X. Feng, J. Maier, and K. Mullen, *Chem. Sus. Chem.*, **3**, 236 (2010).
20. S.L. Chou, J.Z. Wang, M. Choucair, H.K. Liu, J.A. Stride, and S.X. Dou, *Electrochem. Commun.*, **12**, 1388 (2010).
21. S.M. Paek, E. Yoo, and I. Honma, *Nano Letters*, **9**, 1530 (2009).
22. S. Yang, X. Feng, S. Ivanovici, and K. Mullen, *Ang. Chem.*, **49**, 1433 (2010).
23. W. Cho, W. Ra, J. Shirakawa, M. Nakayama, and M. Wakihara, *J. Solid State Chem.*, **179** 3534 (2006).
24. H. Manjunatha, G. S. Suresh, and T. V. Venkatesha, *J. Solid State Electrochem.*, **15**, 431 (2010).
25. M. Jayalakshmi, M. Mohan Rao, and F. Scholz, *Langmuir*, **19**, 8403 (2003).
26. Y.J. Lee, F. Wang, and C.P. Grey, *J. Am. Chem. Soc.*, **120**, 12601 (1991).
27. Y. Xia and M. Yoshio, *J. Electrochem. Soc.*, **143**, 825 (1996).
28. W.R. Mckinnon, R.R. Haering, *Modern Aspects of Electrochemistry*, vol. **15**, Plenum Press, New York (1983).
29. D. Lu, W. Li, X. Zuo, Z. Yuan, and Q. Huang, *J. Phys. Chem. C*, **111**, 12067 (2007).
30. H. Wang, Y. Zeng, K. Huang, S. Liu, and L. Chen, *Electrochim. Acta*, **52**, 5102 (2007).
31. H. Wang, K. Huang, Y. Zeng, F. Zhao, and L. Chen, *Electrochem. Solid-State Lett.* **10**, A199 (2007).